



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

October 3, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG841613972

LABORATORY GROWN DIAMOND

OCTAGONAL STEP CUT

11.08 X 5.60 X 3.50 MM

1.51 CARAT

G

VVS 2

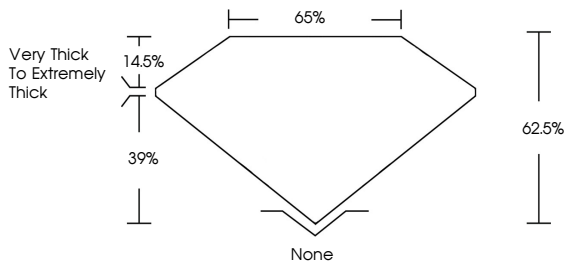
EXCELLENT

EXCELLENT

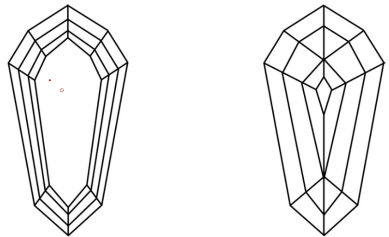
NONE

 LG841613972

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

D	E	F	G	H	I	J	Faint	Very Light	Light
FL	IF	VVS ¹⁻²	VVS ¹⁻²	SI ¹⁻²	SI ¹⁻³				
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included				



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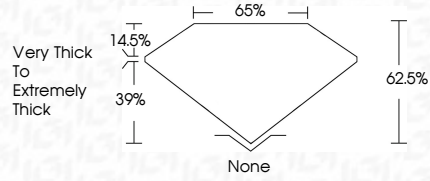
VVS 2

EXCELLENT

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VVS 2

62.5%

65%

Very Thick To Extremely Thick

None

EXCELLENT

EXCELLENT

NONE

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